Photodetection: Absorption => Current Generation



Materials for photodetection: $E_g < hv$ Various methods for generating currents with photo-generated carriers: photoconductors, photodiodes, avalanche photodiodes





Sharp decrease in absorption for photon energy $< E_g$

$$P_{out}/P_{in} = exp(gL)$$

$$g < 0 \rightarrow \alpha = -g$$



- Photodetection for indirect bandgap materials



Absorption in indirect bandgap semiconductor is possible

→ Indirect semiconductors (Si) are used for solar cells and image censors







Photodiodes



PN junction in reverse bias

Photo-generated carriers are removed by built-in field in depletion region (space charge region)

 $-E_o$





Photo-generated carriers drift into P (holes) and N (electrons) regions generating currents

$$I = \eta_{\rm int} \frac{P}{h\nu} q$$

One photon creates a pair of electron and hole





Problem: depletion region is very thin (< 1 μ m) $\rightarrow \eta_{int}$ is very small

=> Use PIN structure



PD with gain?

Avalanche Photodiode (APD)

(avalanche: a large mass of snow, ice, earth, rock, or other material in swift motion down a mountainside)

Achieve gain by multiplying electrons and/or holes.

Impact Ionization: Under high E-field, electrons and holes can have sufficiently high kinetic energies breaking bonds and creating new e-h pairs.



It is preferred only one type of carrier (either electron or hole) causes impact lonization

κ: ratio of ionization coefficients(= hole/electron)



Current Status of Photonics Technology



- Photonics has been very successful in Left
- Photonics has to go to Right in order to maintain its growth
- Telecom Operators \rightarrow Semiconductor Companies
- Data rate, Distance \rightarrow Data rates, Cost, Power
- There is no better platform than Si



Ultimate Solution: Si Electronic-Photonic Integration



If interested, come and see me!

